## **Crystal Defects**

**Perfect crystal** - every atom of the same type in the correct equilibrium position (does not exist at T > 0 K)

**Real crystal** - all crystals have some imperfections - **defects** most atoms are in ideal locations, a small number are out of place

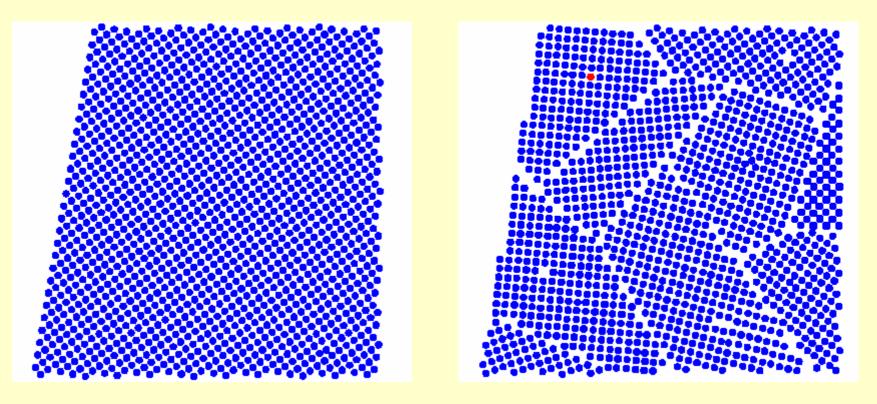
- Intrinsic defects present for thermodynamic reasons
- Extrinsic defects not required by thermodynamics, can be controlled by purification or synthetic conditions
- Chemical defects (foreign atom, mixed crystals, nonstoichiometry)
- Geometrical defects (vacancy, interstitials, dislocations, boundaries, surface)

Defects dominate the material properties: Mechanical, Chemical, Electrical, Diffusion

#### **Crystal Defects**

Perfect crystal

Real crystal



### **Classes of Crystal Defects**

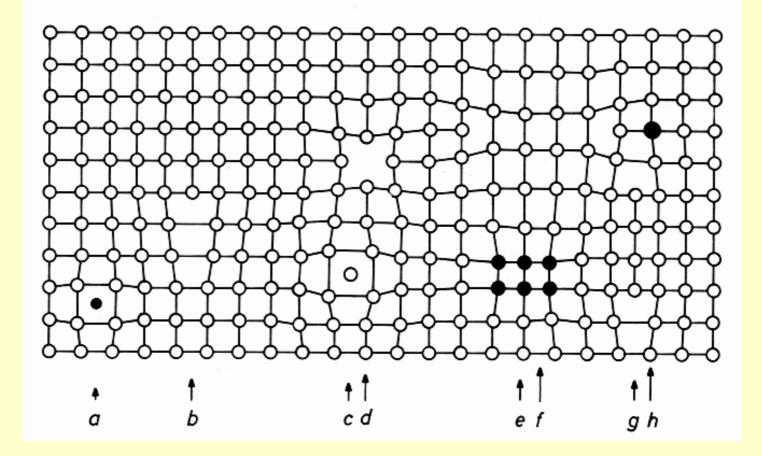
**Point defects** (0D) places where an atom is missing or irregularly placed in the lattice structure – lattice vacancies, self-interstitial atoms, substitution impurity atoms, interstitial impurity atoms

**Linear defects** (1D) groups of atoms in irregular positions – dislocations

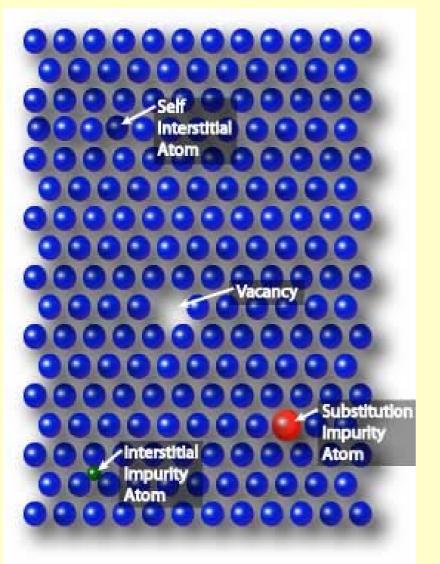
**Planar defects** (2D) interfaces between homogeneous regions of the material - grain boundaries, stacking faults, external surfaces

**Volume defects** (3D) spaces of foreign matter – pores, inclusions

#### **Classes of Crystal Defects**



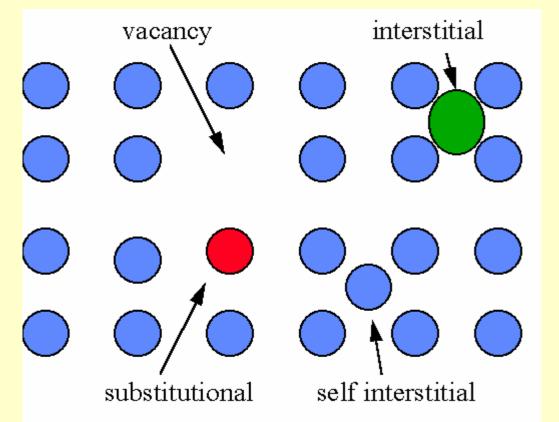
## **Point Defects**



Point defects - an atom is missing or is in an irregular position in the lattice

- self interstitial atoms
- interstitial impurity atoms
- substitutional atoms
- vacancies

## **Point Defects**

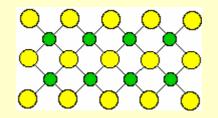


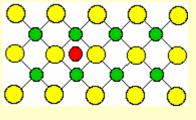
Point defects - an atom is missing or is in an irregular position in the lattice

- self interstitial atoms
- interstitial impurity atoms
- substitutional atoms
- vacancies

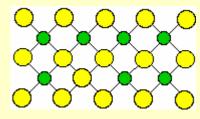
### **Point Defects – Ionic Compounds**

perfect crystal lattice AB

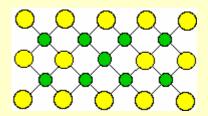




interstitial imputity

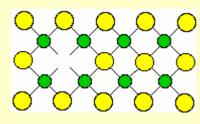


**B**<sub>A</sub> antisite defect

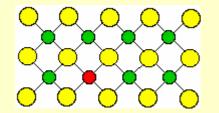


**A**<sub>B</sub> antisite defect

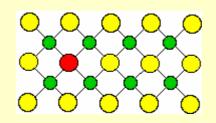
cation vacancy



anion vacancy



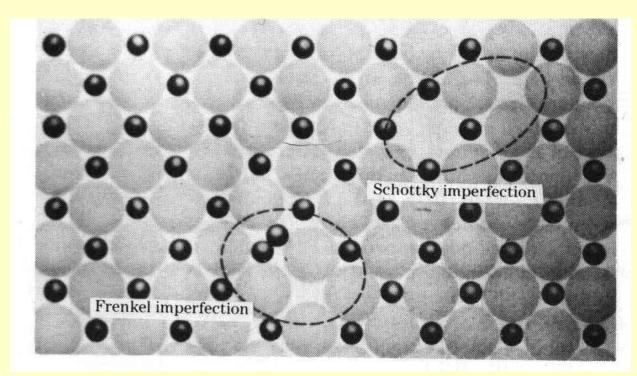
substitution of a cation



substitution of an anion

## **Types of Point Defects in Ionic Compounds**

- Vacancy
- Interstitial
- Substitutional
- Frenkel
- Schottky



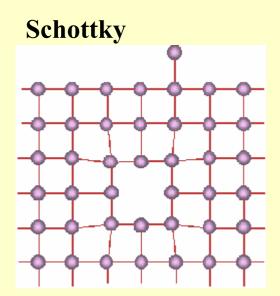
Schottky: a pair of vacancies, missing cation/anion moved to the surface

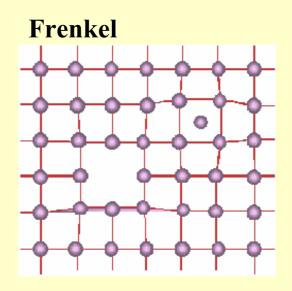
Frenkel: ions moved to interstitial positions, vacancies

#### **Point Defects**

**Schottky** - equal numbers of vacancies at both A and B sites preserving charge balance, found in compounds where metal ions are able to assume multiple oxidation states

**Frenkel** – found in open structures (wurtzite, sphalerite, etc) with low coordination numbers, open structure provides room for interstital sites to be occupied



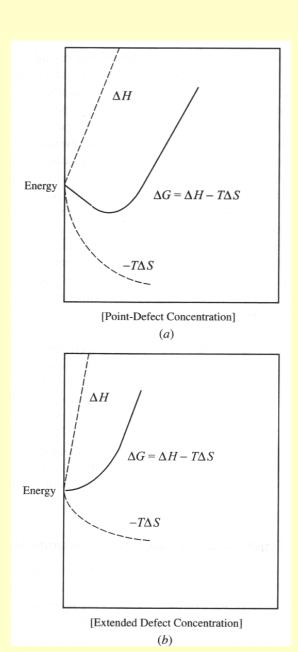


#### Vacancies

- There are naturally occurring vacancies in all crystals
- Equilibrium defects thermal oscillations of atoms at T > 0 K
- The number of vacancies increases as the temperature goes up
- The number of vacancies

$$N_V = N \exp\left(-\frac{\Delta H^a}{RT}\right)$$

- N is the total number of sites in a crystal
- N<sub>v</sub> is the number of vacancies
- $\Delta H^a$  is the activation energy for the formation of a vacancy
- R is the gas constant
- $N_v$  goes up exponentially with temperature T



# **Crystal Energies** $\Delta G = \Delta H - T \Delta S$

Point defects = equilibrium concentration, Enthalpy is positive, configurational entropy positive Minimum on free energy

Extended defects = no equilibrium concentration, Enthalpy is HIGHLY positive, configurational entropy cannot outweight, no minimum on free energy

Metastable – dislocations, grain boundaries, surface

Heating - minimize free energy: polycrystalline → single crystal grain growth Grains with high dislocation density consumed Atoms move across grain boundary

## **Interstitial Atoms**

- An atom must be small to fit into the interstitial voids
- H and He can diffuse rapidly through metals by moving through the interstitial voids
- Interstitial C is used to strengthen Fe = steel, it distorts the matrix
- The ratio of r/R is 0.57 needs an octahedral hole
- Octahedral and tetrahedral holes in both FCC and BCC however the holes in BCC are not regular polyhedra
- The solubility of C in FCC-Fe is much higher than in BCC-Fe

#### **Typical point defects in crystals**

Alkali halides Alkaline earth oxides Silver halides Alkaline earth fluorides Schottky (cations and anions) Schottky (cations and anions) Frenkel (cations) Frenkel (anions)

#### **Typical activation energies for ion diffusion**

Na <sup>+</sup> in NaCl	~ 0,7 eV
Cl <sup>-</sup> in NaCl	~ 1 eV
Schottky pair	~ 2,3 eV

(1 eV/molecule = 96.49 kJ/mol)

## **Extrinsic Defects**

The addition of the **dopant** (an impurity) into a perfect crystal = point defects in the crystal

NaCl heated in Na vapors Na is taken into the crystal and changes the compostion

 $NaCl \rightarrow Na_{l+x}Cl$ 

Na atoms occupy cation sites an equivalent number of unoccupied anion sites Na atoms ionize, Na<sup>+</sup> ions occupy the cation sites, the electrons occupy the anion vacancies – **F centers** – color

This solid is now a **non-stoichiometric** compound as the ratio of atoms is no longer the simple integer

### **Non-stoichiometric Compounds**

Vanadium oxide varies from  $VO_{0.79}$  to  $VO_{1.29}$ 

other examples:  $TiO_x$ ,  $Ni_xO$ ,  $UO_x$  and  $Li_xWO_3$ 

Covalent compounds - held to together by very strong covalent bonds which are difficult to break, do not show a wide range of composition

Ionic compounds - do not show a wide range because a large amount of energy is required to remove / add ions

Non-stoichiometry can be caused by doping or by a multi-valent element

## **Non-stoichiometric Compounds**

#### Non-stoichiometric ionic crystals

a multi-valent element - changes in the number of ions can be compensated for by changes in the charge on the ions, therefore maintaining charge balance but changing the stoichiometry

non-stoichiometric compounds have formulae with non-integer ratios and can exhibit a range of compositions.

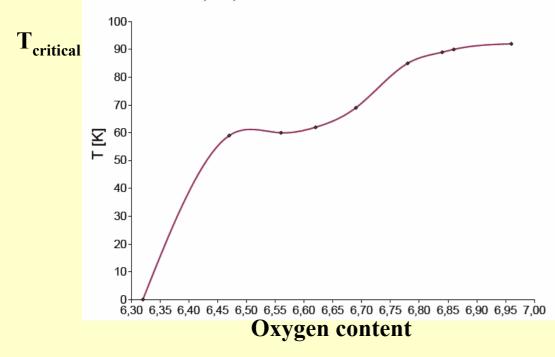
They are formed by introducing an impurity (doping) or by the ability of an element to show multi-valent character.

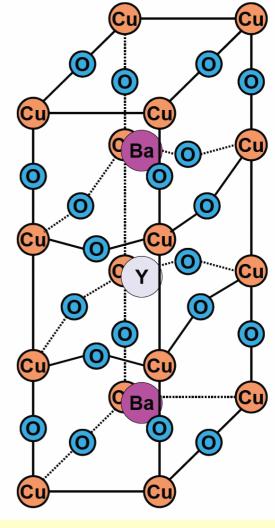
The electronic, optical, magnetic and mechanical properties of nonstoichiometric compounds can be controlled by varying their composition.

#### **Non-stoichiometric Compounds**

Non-stoichiometric superconductor YBCO YBa<sub>2</sub>Cu<sub>3</sub>O<sub>6,5</sub> a multi-valent element = Cu

YBa<sub>2</sub>Cu<sub>3</sub>O<sub>6,8-7,0</sub> 90 K supenductor YBa<sub>2</sub>Cu<sub>3</sub>O<sub>6,45-6,7</sub> 60 K superconductor YBa<sub>2</sub>Cu<sub>3</sub>O<sub>6,0-6,45</sub> antiferromagnetic semiconductor

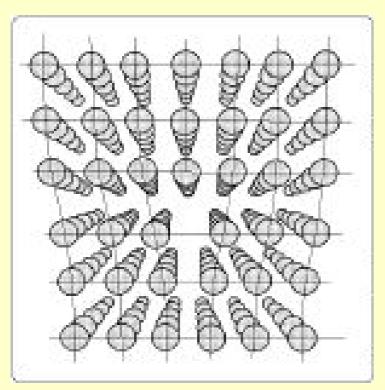


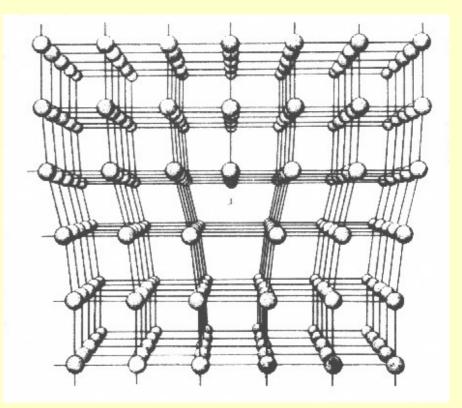


## **Dislocations**

Line imperfections in a 3D lattice

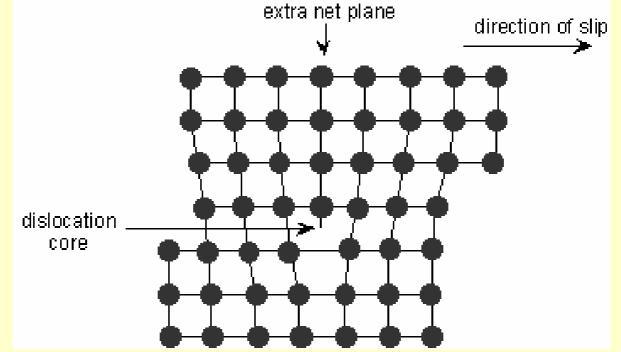
- Edge
- Screw
- Mixed



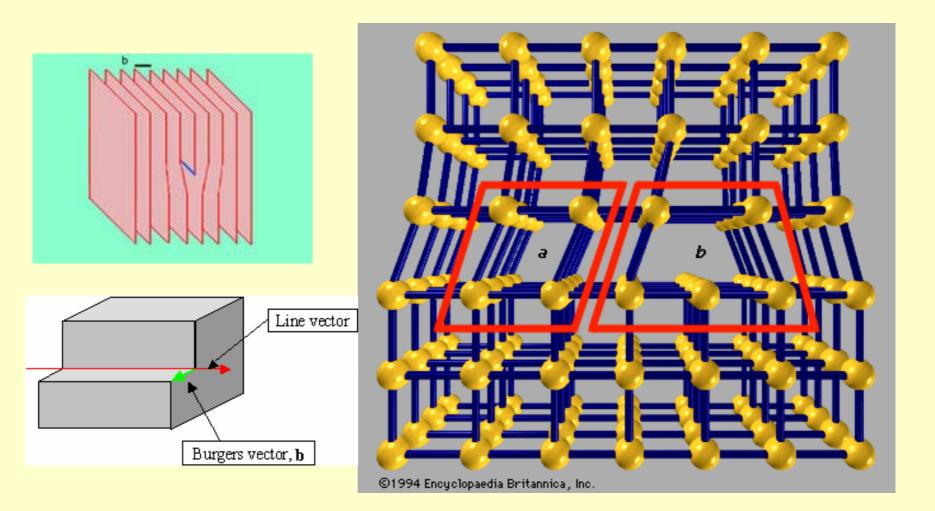


## **Edge Dislocation**

- Extra plane of atoms
- Burgers vector
  - Deformation direction
  - For edge dislocations it is perpendicular to the dislocation line

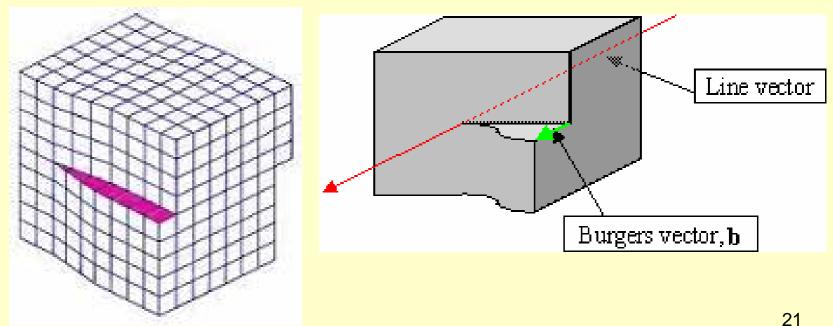


## **Edge Dislocation**

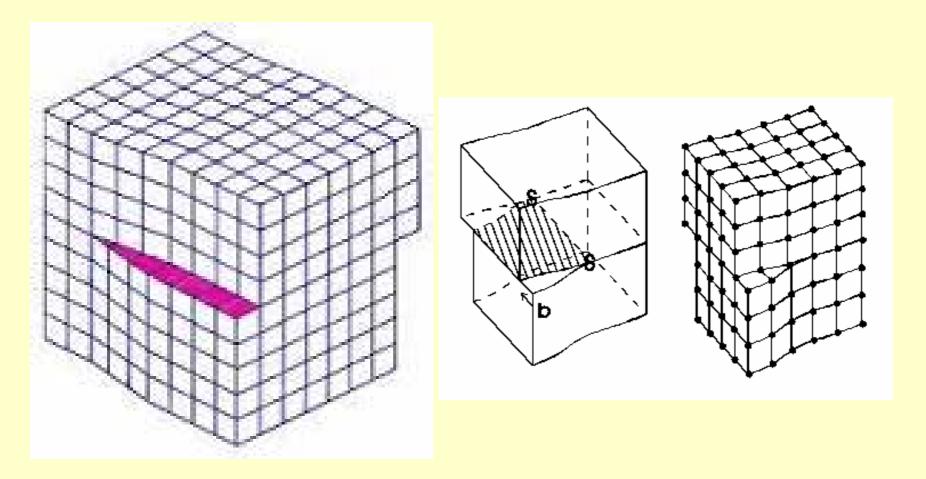


## **Screw Dislocation**

- A ramped step
- Burgers vector
  - Direction of the displacement of the atoms
  - For a screw dislocation it is parallel to the line of the dislocation



#### **Screw Dislocation**



## Deformation

When a shear force is applied to a material, the dislocations move Plastic deformation in a material occurs due to the movement of dislocations (linear defects)

The strength of the material depends on the force required to make the dislocation move, not the bonding energy Millions of dislocations result from plastic forming operations such as rolling and extruding

Any defect in the regular lattice structure (point, planar defects, other dislocations) disrupts the motion of dislocation - makes slip or plastic deformation more difficult

## Deformation

Dislocation movement produces additional dislocations

Dislocations collide – entangle – impede movement of other dislocations - drives up the force needed to move the dislocation strengthens the material

Applying a force to the material increases the number of dislocations

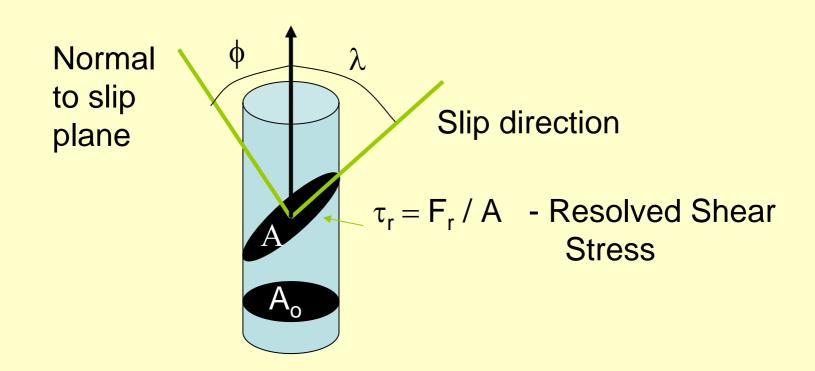
Called "strain hardening" or "cold work"

## Slip

- When dislocations move slip occurs
  - Direction of movement same as the Burgers vector
- Slip is easiest on close packed planes
- Slip is easiest in the close packed **direction**
- Affects
  - Ductility
  - Material Strength

## Schmidt's Law

• In order for a dislocation to move in its slip system, a shear force acting in the slip direction must be produced by the applied force.  $\sigma = F/A$ 



## Schmidt's Law

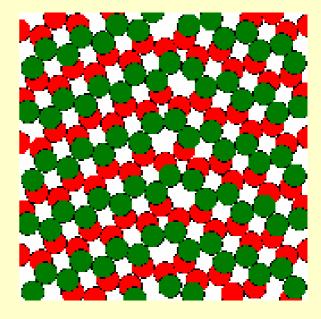
- $F_r = F \cos(\lambda)$
- $A = A_0 / \cos(\phi)$
- $\tau = \sigma \cos(\phi) \cos(\lambda)$

Where:

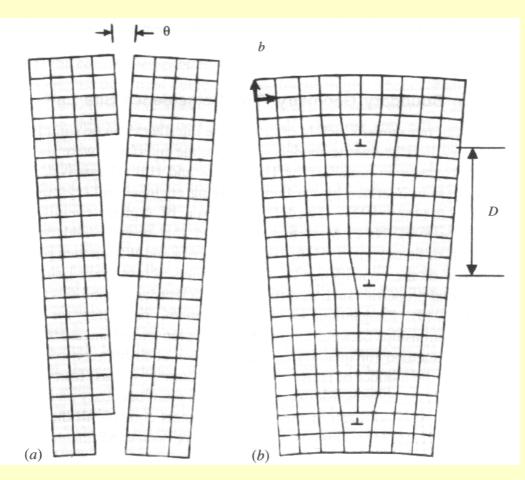
 $\tau = F_r / A$  = resolved shear stress in the slip direction  $\sigma = F/A_o$  = unidirectional stress applied to the cylinder

## **Surface and Grain Boundaries**

- The atoms at the boundary of a grain or on the surface are not surrounded by other atoms lower CN, weaker bonding
- Grains line up imperfectly where the grain boundaries meet
- Dislocations can usually not cross grain boundaries
- Tilt and Twist boundaries
- Low and High angle boundaries



#### **Low Angle Tilt Boundary**

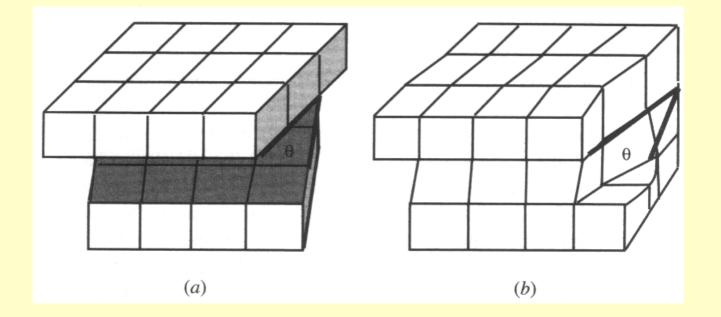


Low Angle Tilt Boundary = Array of Edge dislocations

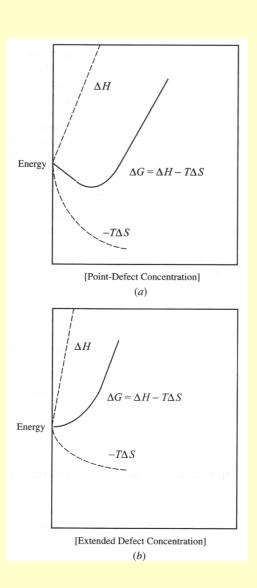
 $D = \frac{b}{\sin \theta}$ 

D = dislocation spacing b = Burgers vector θ = misorientation angle

#### **Low Angle Twist Boundary**



Low Angle Twist Boundary = a Screw dislocation



## **Crystal Energies**

Point defects = equilibrium concentration, Enthalpy is positive, configurational entropy positive Minimum on free energy

Extended defects = no equilibrium concentration, Enthalpy is HIGHLY positive, configurational entropy cannot outweight, no minimum on free energy

Metastable – dislocations, grain boundaries, surface

Heating - minimize free energy: polycrystalline → single crystal grain growth Grains with high dislocation density consumed Atoms move across grain boundary

## **Effect of Grain Size on Strength**

- In a small grain, a dislocation gets to the boundary and stops slip stops
- In a large grain, the dislocation can travel farther
- Small grain size equates to more strength

## **Hall-Petch Equation**

 $\sigma_y = \sigma_0 + K \ d^{-1/2}$ 

 $\sigma_y$  = yield strength (stress at which the material permanently deforms)

- d = average diameter of the grains
- $\sigma_0 = constant$
- K = constant

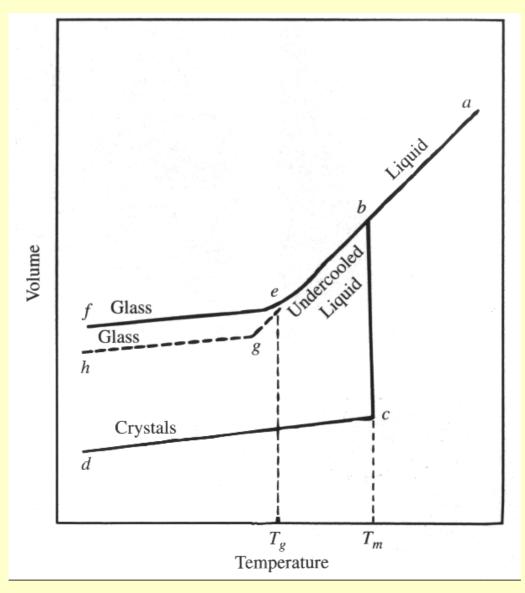
## **Control of the Slip Process**

- Strain hardening
- Solid Solution strengthening
- Grain Size strengthening

## **Amorphous Structures**

- Cooling a material off too fast it does not have a chance to crystallize
- Forms a glass
- Easy to make a ceramic glass
- Hard to make a metallic glass
- There are no slip planes, grain boundaries in a glass

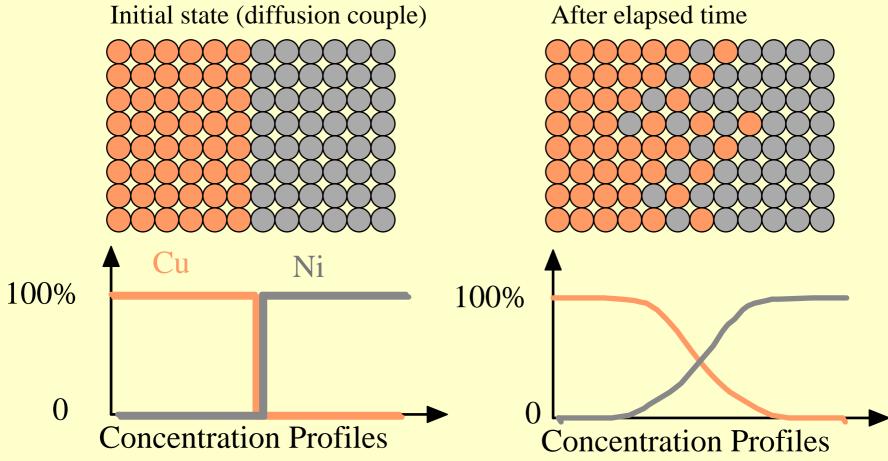
#### **Amorphous Structures**



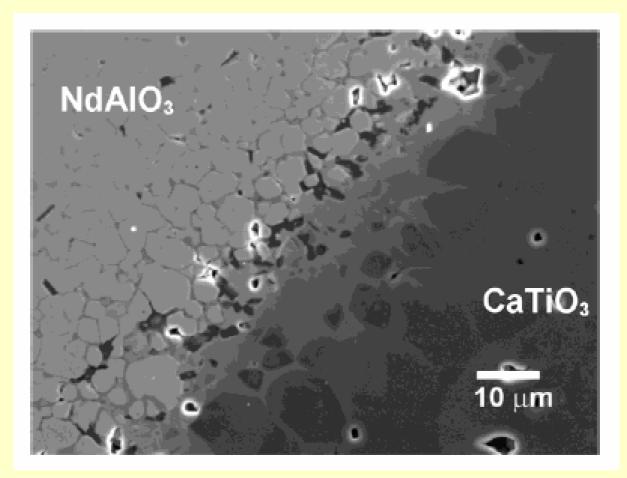
36

#### Diffusion

Interdiffusion: atoms migrate from regions of large to lower concentration



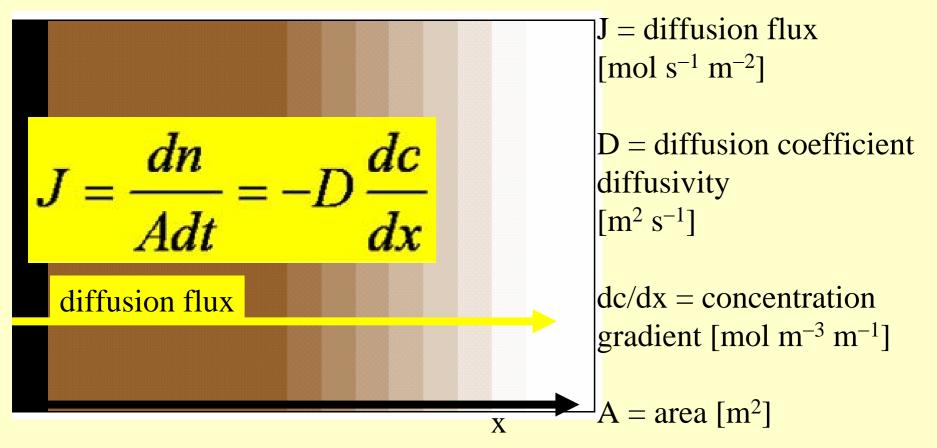
#### Diffusion



CaTiO<sub>3</sub>-NdAlO<sub>3</sub> diffusion couple fired at 1350 °C/ 6 h

#### **Diffusion - Fick's First Law**

Fick's first law describes steady-state diffusion



Velocity of diffusion of particles (ions, atoms ...) in a solid mass transport and concentration gradient for a given point in a solid

39

#### **Diffusion - Fick's First Law**

Typical diffusion coefficients for ions (atoms) in a solid at room temperature are about 10<sup>-13</sup> cm<sup>2</sup> s<sup>-1</sup>.

In solid state ionic conductors (e.g. Ag-ions in  $\alpha$ -AgI) the values are greater by orders of magnitude ( $\approx 10^{-6}$  cm<sup>2</sup> s<sup>-1</sup>)

### **Mechanisms of Diffusion**

**Diffusion** = the mechanism by which matter is transported into or through matter

Diffusion at the atomic level is a step-wise migration of atoms from lattice site to lattice site

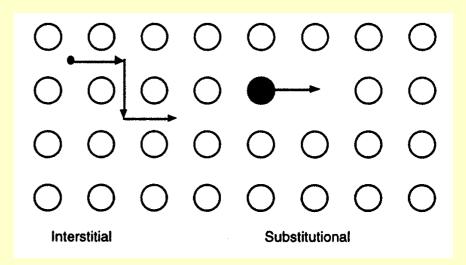
#### **Conditions** for diffusion:

- an adjacent empty site
- atom possesses sufficient **energy** to break bonds with its neighbors and migrate to adjacent site (activation energy)

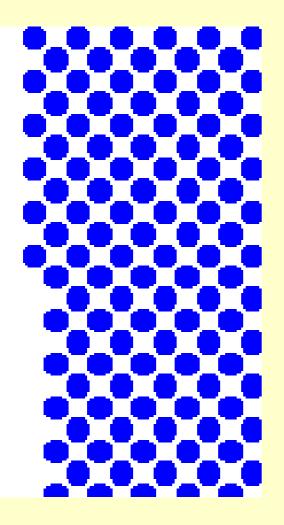
The higher the **temperature**, the higher is the probability that an atom will have sufficient energy diffusion rates increase with temperature

#### **Mechanisms of Diffusion**

- Along Defects = Vacancy (or Substitutional) mechanism
  - Point Defects
  - Line Defects
- Through Interstitial Spaces = Interstitial mechanism
- Along Grain Boundaries
- On the Surface



#### **Vacancy Mechanisms of Diffusion**



- Vacancies are holes in the matrix
- Vacancies are always moving
- An impurity can move into the vacancy
- Diffuse through the material



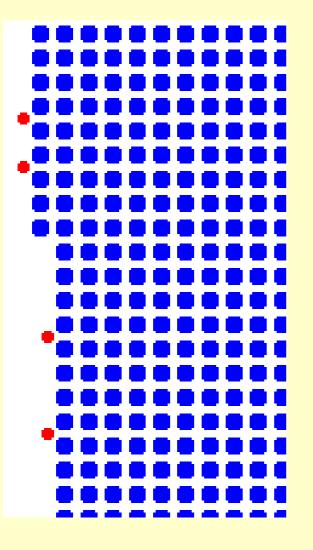
#### **Vacancy Mechanisms of Diffusion**

Atoms can move from one site to another if there is sufficient energy present for the atoms to overcome a local activation energy barrier and if there are vacancies present for the atoms to move into.

The activation energy for diffusion is the sum of the energy required to form a vacancy and the energy to move the vacancy.

increasing elapsed time

#### **Interstitial Mechanisms of Diffusion**



- There are holes between the atoms in the matrix
- If the atoms are small enough, they can diffuse through the interstitial holes
- Fast diffusion

#### **Interstitial Mechanisms of Diffusion**

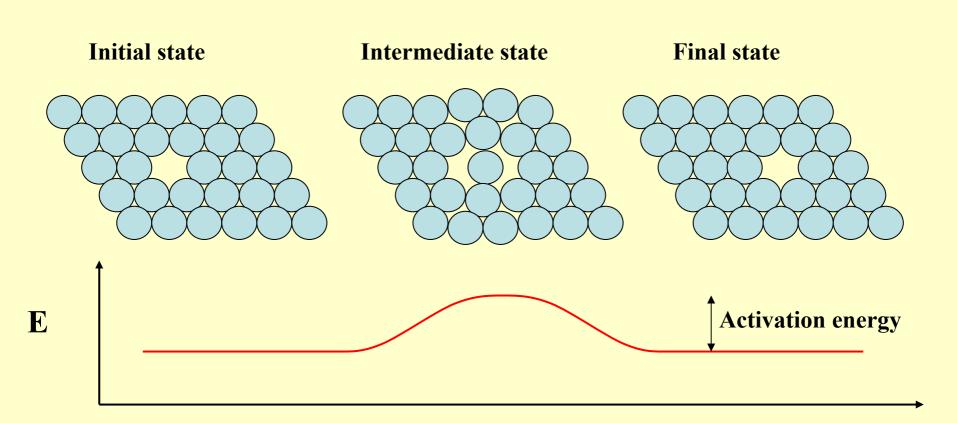
Interstitial atoms like hydrogen, helium, carbon, nitrogen, etc. must squeeze through openings between interstitial sites to diffuse around in a crystal.

The activation energy for diffusion is the energy required for these atoms to squeeze through the small openings between the host lattice atoms.

## **Activation Energy**

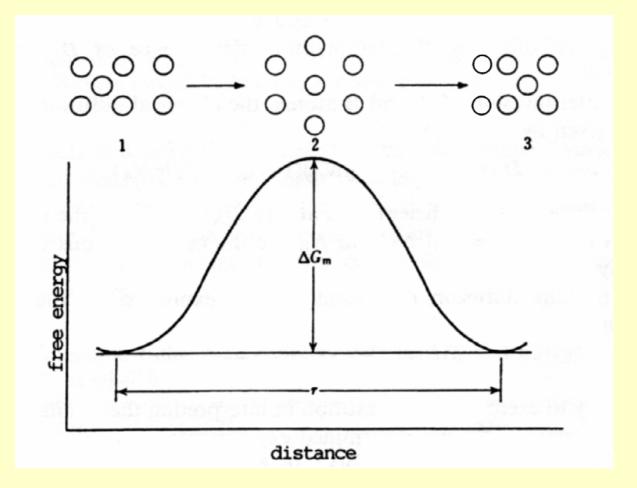
- All the diffusion mechanisms require a certain minimum energy to occur
- The activation energy
- The higher the activation energy, the harder it is for diffusion to occur
- The highest energy is for volume diffusion
  - Vacancy
  - Interstitial
- Grain Boundary diffusion requires less energy
- Surface Diffusion requires the least

### **Activation Energy**



**Energy barrier for diffusion** 

#### **Energy Barrier for Diffusion**



#### **Diffusion Rate**

$$D = D_{\infty} \exp\left(-\frac{Q}{RT}\right)$$

Diffusion coefficients show an exponential temperature dependence (Arrhenius type)

- **D** = the diffusivity, which is proportional to the diffusion rate
- $\mathbf{D}_{\infty} = \mathbf{D}$  for  $\mathbf{T} \rightarrow \infty$
- **Q** = the activation energy
- **R** = the gas constant
- **T** = the absolute temperature

D is a function of temperature

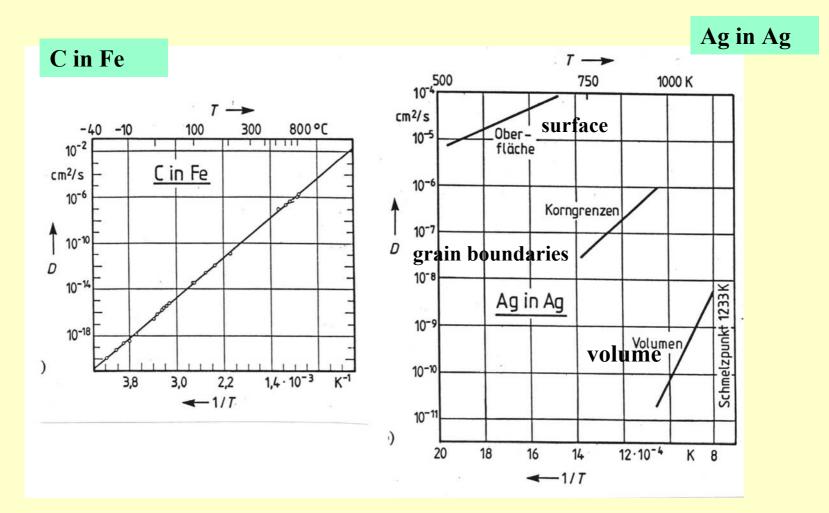
Thus the flux (J) is also a function of temperature

High activation energy corresponds to low diffusion rates

The logarithmic representation of D verus 1/T is linear, the slope corresponds

to the <u>activation energy</u> and the <u>intercept</u> to  $\underline{D}_{\infty}$ 

## **Diffusion Coefficients**



#### Diffusion

Velocity of diffusion of particles (ions, atoms ...) in a solid

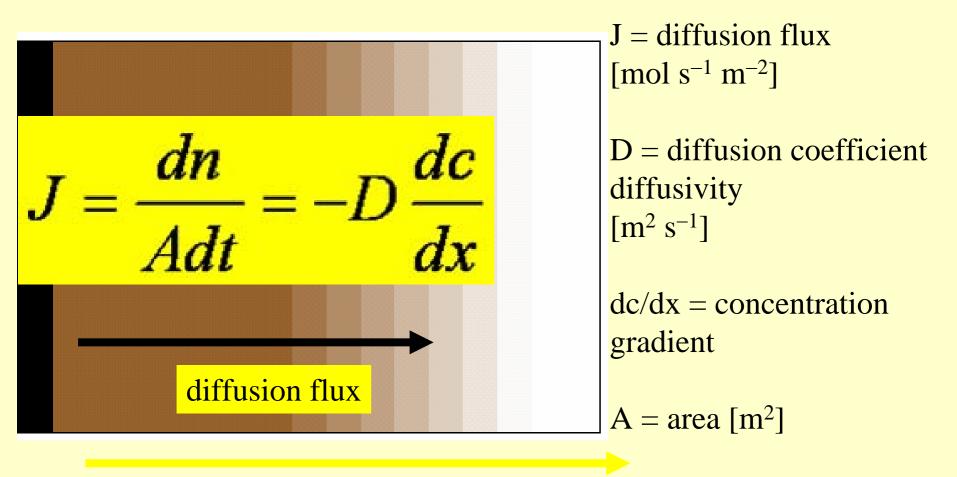
- mass transport and concentration gradient for a given point in a solid!

$$J = \frac{dn}{Adt} = -D\frac{dc}{dx} \text{ [mol cm}^2 \text{ s}^{-1}\text{] (const. T)}$$

 $J_i: flow of diffusion (mol s<sup>-1</sup> cm<sup>-2</sup>); D_i: diffusion coefficient (cm<sup>2</sup> s<sup>-1</sup>) \\ \delta c_i / \delta x: concentration gradient (mol cm<sup>-3</sup> cm<sup>-1</sup>) (i.e. change of concentration along a line in the solid!)$ 

#### **Diffusion - Fick's First Law**

Fick's first law describes steady state diffusion



Typical diffusion coefficients for ions (atoms) in a solid at room temperature are about 10<sup>-13</sup> cm<sup>2</sup> s<sup>-1</sup>.

In solid state ionic conductors (e.g. Ag-ions in  $\alpha$ -AgI) the values are greater by orders of magnitude ( $\approx 10^{-6}$  cm<sup>2</sup> s<sup>-1</sup>)

Knowledge of D allows an estimation of the <u>average diffusion length</u> for the migrating particles:

 $\langle x^2 \rangle = 2Dt$  ( $\langle x^2 \rangle$ : average square of diffusion area; t: time)

# Diffusion coefficients show an exponential temperature dependence (Arrhenius type):

 $\mathbf{D} = \mathbf{D}_{\infty} \exp(-\mathbf{Q}/\mathbf{kT}) \quad (\mathbf{D}_{\infty}: \mathbf{D} \text{ for } \mathbf{T} \rightarrow \infty, \mathbf{Q}: \text{ activation energy} \\ \text{ of diffusion, } \mathbf{k}: \text{ Boltzmann-faktor})$ 

The logarithmic representation of D verus 1/T is linear, the <u>slope</u> corresponds to the <u>activation energy</u> and the <u>intercept</u> to  $\underline{D}_{\infty}$ .

